PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q80899

Takashi UDAGAWA

Appln. No.: 10/594,683

Group Art Unit: 1722

Confirmation No.: 2074

Examiner: Kevin V. OUINTO

Filed: September 28, 2006

For: COMPOUND SEMICONDUCTOR DEVICE, PRODUCTION METHOD OF

COMPOUND SEMICONDUCTOR DEVICE AND DIODE

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §§ 1.97 and 1.98

MAIL STOP AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Sir:

In accordance with the duty of disclosure under 37 C.F.R. § 1.56, Applicant hereby notifies the U.S. Patent and Trademark Office of the documents which are listed on the attached PTO/SB/08 A & B (modified) form and/or listed herein and which the Examiner may deem material to patentability of the claims of the above-identified application.

One copy of each of the listed documents is submitted herewith, along with a copy of the corresponding Communication from a Foreign Patent Office (German Office Action dated April 4, 2008 for corresponding German Application No. 11 2005 000 529), except for the following: U.S. patents and/or U.S. patent publications; and co-pending non-provisional U.S. applications filed after June 30, 2003.

The present Information Disclosure Statement is being filed after the later of three months from the application's filing date and the mailing date of the first Office Action on the merits, but before a Final Office Action, Notice of Allowance, or an action that otherwise closes prosecution in the application (whichever is earlier), and therefore Applicant is filing

INFORMATION DISCLOSURE STATEMENT

UNDER 37 C.F.R. §§ 1.97 and 1.98 U.S. Appln. No.: 10/594,683

concurrently herewith a Statement Under 37 C.F.R. § 1.97(e). No fee under 37 C.F.R. § 1.17(p) is required.

Applicant notes that the article of T.L. CHU, et al., "CRYSTAL AND EPITAXIAL LAYERS OF BORON PHOSPHIDE", JOURNAL OF APPLIED PHYSICS, Vol. 42, No. 1, January 1991, pp. 420-424 listed in the German Office Action was previously submitted in the Information Disclosure Statement filed September 28, 2006.

The submission of the listed documents is not intended as an admission that any such document constitutes prior art against the claims of the present application. Applicant does not waive any right to take any action that would be appropriate to antedate or otherwise remove any listed document as a competent reference against the claims of the present application.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

Attorney Docket No.: Q80899

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WASHINGTON OFFICE 23373
CUSTOMER NUMBER

Date: May 28, 2008

Abraham J. Rosner Registration No. 33,276

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STATEMENT UNDER 37 C.F.R. § 1.97(e)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 Sir:

The undersigned hereby states, upon information and belief:

That each item of information contained in the Information Disclosure Statement filed concurrently herewith was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of said Information Disclosure Statement.

Respectfully submitted,

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